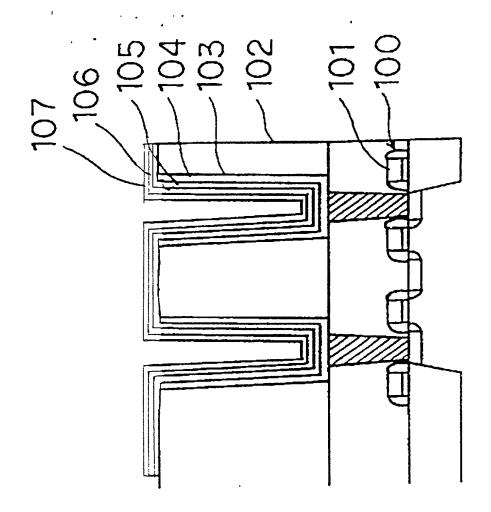
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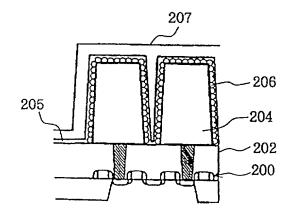
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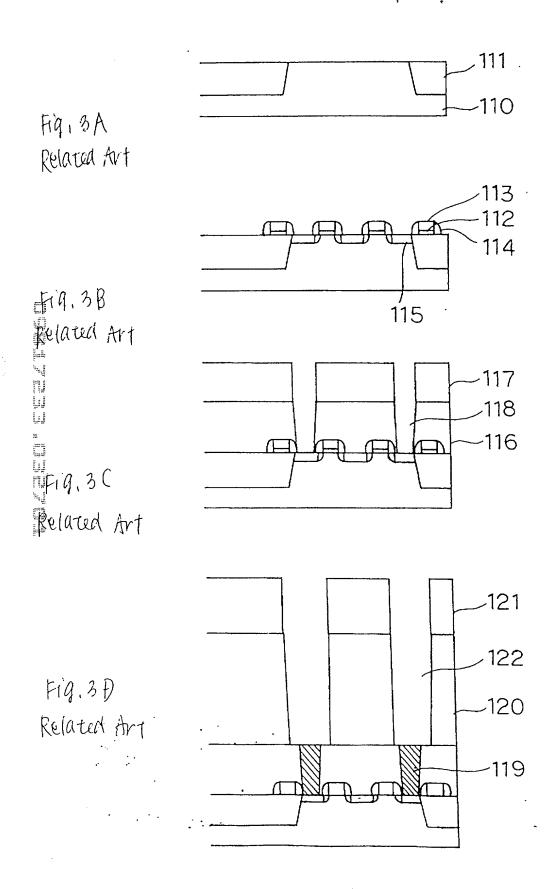
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Fig. 2
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fig.3 E Related Art

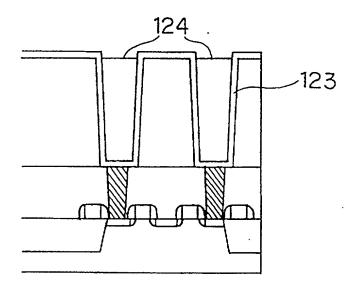
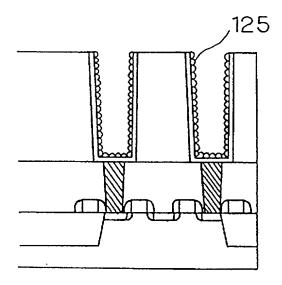


Fig. 3F
Related Art



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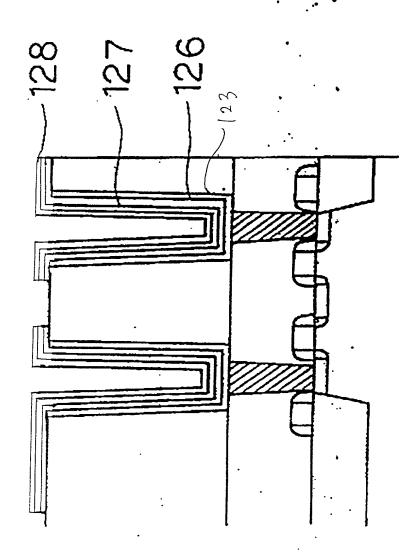
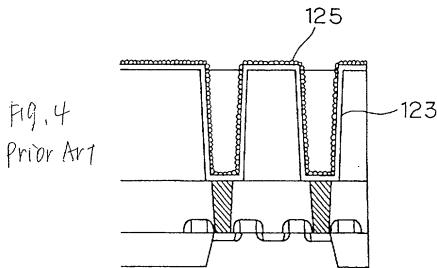


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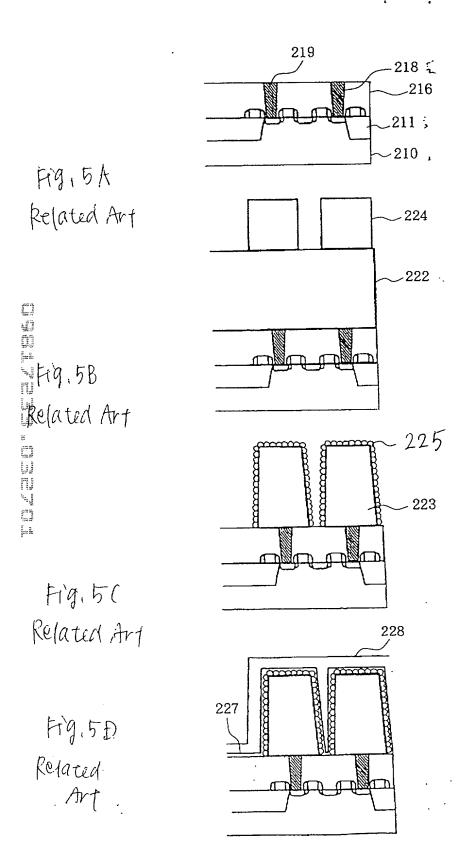
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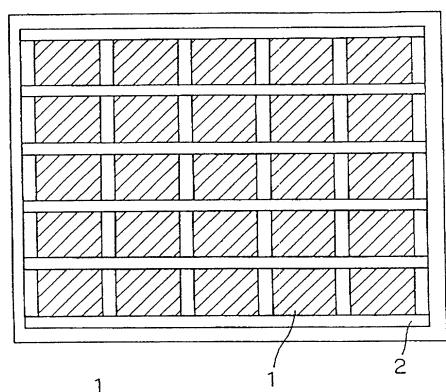


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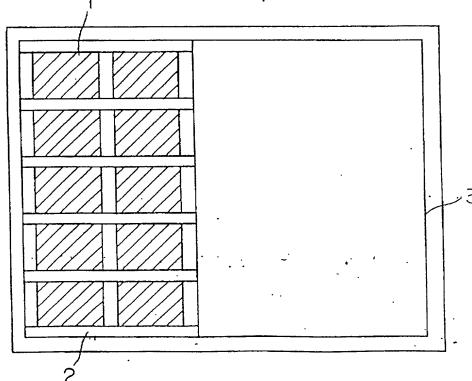
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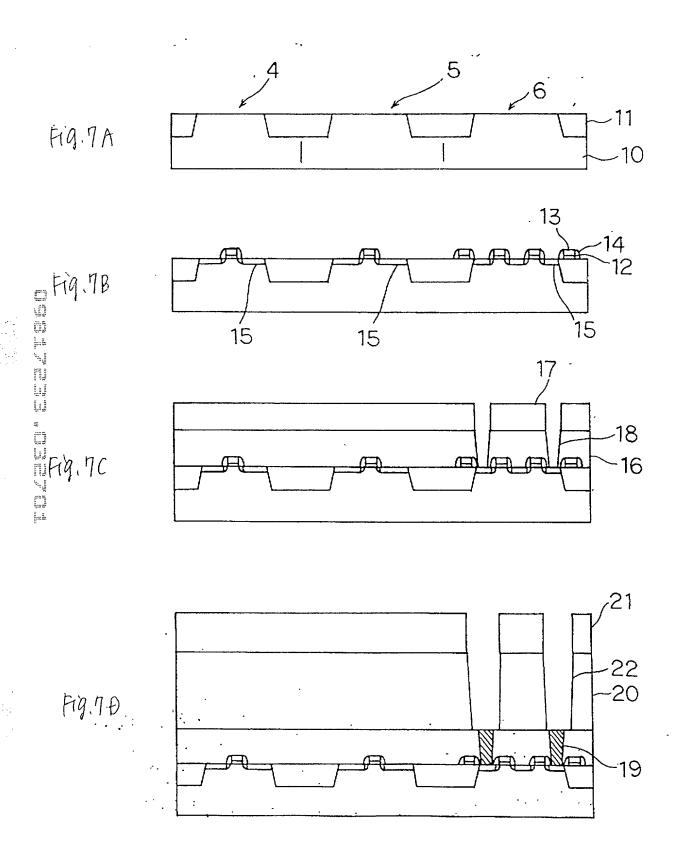
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Fig.68



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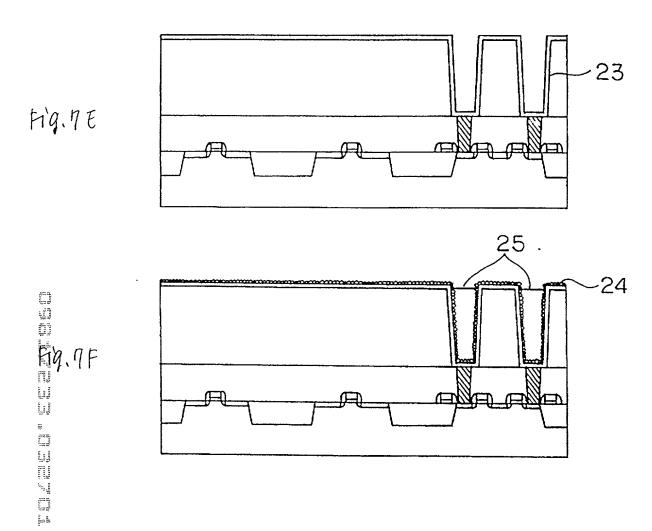
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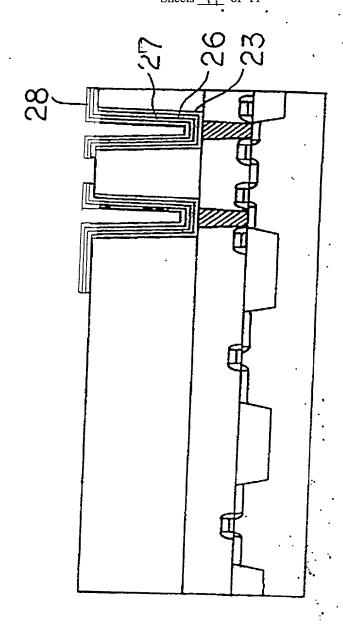
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